Direct Nanoscale Imaging of Ballistic and Diffusive Thermal Transport in Graphene Nanostructures

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ABSTRACT: We report direct imaging of nanoscale thermal transport in single and few-layer graphene with approximately 50 nm lateral resolution using high vacuum scanning thermal microscopy. We observed increased heat transport in suspended graphene where heat is conducted by ballistic phonons, compared to adjacent areas of supported graphene, and observed decreasing thermal conductance of supported graphene with increased layer number. Our nanothermal images suggest a mean-free-path of thermal phonons in supported graphene below 100 nm.

KEYWORDS: Nanoscale thermal transport, nanoscale imaging, ballistic phonons, thermal conductivity, graphene, scanning thermal microscopy

The list of graphene properties showing potential for nanoelectronics applications includes high carrier mobility, superior mechanical strength, and high thermal conductivity.1−3 While graphene electronic properties have been extensively studied at scales ranging from micrometer down to nanometer, the nanometer length scale investigation of heat transfer in graphene nanostuctures is still a largely unexplored area. Findings reported to date point to the extraordinary thermal properties of graphene as a two-dimensional (2D) nanomaterial,4−10 suggesting that supported and free-standing films of graphene can be used for heat management in nanoscale devices. With the mean-free-path (MFP) of thermal phonons at room temperature in graphene estimated to be in the order of 250−800 nm6,11,12 and the typical feature size of modern electronic devices in the order of a few tens of nanometers, it is apparent that the ballistic regime must play a significant role in thermal transport in graphene-based nanodevices.13 This highlights the importance of exploration of heat generation and transport in such devices with nanoscale spatial resolution. So far that was not possible, as these phenomena have been studied either in stationary devices9,14 in experiments using micro-Raman spectroscopy with lateral resolution inevitably restricted by the optical wavelength to the range of 0.5−1 μm4,6 and relatively low temperature sensitivity.

In this Letter, we address the challenge of exploring thermal phenomena in graphene nanostuctures by using a nanoscale scanning thermal probe in a high vacuum (HV) environment that allowed us to directly map thermal transport in suspended and supported graphene layers with nanoscale resolution and to explore both ballistic and diffusive regimes of heat transfer. We compare measured thermal resistance measurements Rc of a SiO2 tip-graphene thermal junction for different number of graphene layers and for a suspended versus supported bilayer on a 180 nm wide channel (Figure 1a) where ballistic transport effects can be directly observed. We also perform a theoretical calculation of the MFP of phonons on supported graphene. This find is further supported by profile thermal maps measured at interlayer boundaries.

The thermal conductivity of graphene sheet materials, k, has the highest known value in nature, both theoretically predicted, 6600 W/mK for an isolated unzipped carbon nanotube graphene layer,15 and experimentally measured, 5300 W/mK for micrometer-sized flakes of suspended single-layer graphene (SLG).8 In thin graphene layers, the relative contribution to the total heat conductivity of out-of-plane flexural phonons (ZA), and in-plane transverse (TA) and longitudinal acoustic (LA) phonons depends on the complex interplay10 between phonon density of states (favoring ZA phonons), group velocity (higher for LA and TA phonons)16 as well as higher order nonlinearities.17 The size-dependent heat conduction in 2D systems should also be taken into account.18 In view of current knowledge,10,17 it is reasonable to consider that all acoustic modes contribute to approximately similar extent to the heat conductivity in suspended graphene at room temperature with ZA contribution decreasing as the temperature increases, and electrons in undoped graphene contributing less than 1%.8−10

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Previous measurements of heat transport investigated diffusive thermal transport regime either using fixed “thermal bridge” configuration or graphene in contact with supporting substrate and yielded $k$ of 600 W/mK, or used innovative optical Raman measurements.\textsuperscript{6,8,18} This value is an order of magnitude lower than that of suspended graphene, suggesting that heat transport by all acoustic phonons in supported graphene is suppressed by interaction with the substrate with out-of-plane ZA phonons contribution affected the most.\textsuperscript{17}

In the present study, to investigate nanoscale graphene thermal properties, the graphene samples were prepared by mechanical microcleavage exfoliation of graphite\textsuperscript{1,3,19} followed by deposition onto Si/SiO$_2$ substrates that have prepatterned sharp trenches of 180 nm wide and 300 nm deep. The test samples consisted of suspended and supported sheets of single, double, and multilayer graphene. The presence, number of layers, and location of graphene was determined by Raman,\textsuperscript{20} optical contrast,\textsuperscript{6,21,22} bidirectional topography, and friction atomic force microscopy (AFM) measurements. Micro-Raman and optical contrast were used for identifying relatively wide 1–3 layer graphene areas that subsequently were utilized as a base reference for z-calibrated AFM topography for identifying thickness of thin and thick multilayer graphene. Suspension of graphene over the trench and in delaminated areas was confirmed by AFM contact compliance measurements.\textsuperscript{23} Edge lithography was used to define trenches on the oxidized silicon substrate surface.\textsuperscript{24}

For thermal transport measurement we developed a specialized HV (pressure $\sim10^{-7}$ Torr) scanning thermal probe microscope\textsuperscript{25,26} (SThM) that uses a microfabricated thermal sensor on a force sensitive cantilever, see Figure 1b. The setup allowed us to map locally the heat flow into the sample with a lateral resolution of approximately 50 nm, providing an order of magnitude better spatial resolution for thermal transport in graphene than previously reported.\textsuperscript{4,6}

During measurements the SThM sensor was heated by a constant power Joule heating and as the probe was scanned in a raster way across the sample at a constant force, the sensor temperature was monitored, producing SThM maps. The SThM was based on a microfabricated resistive probe\textsuperscript{27,28} from Anasys Instruments (EXP-GLAI) and consists of a heater-temperature sensor probe with metallic resistive layer of 5 nm NiCr and 40 nm Pd deposited on top of a 1 $\mu$m thick SiO$_2$ cantilever. SThM scans were performed using standard AFM force feedback at constant force that allowed us to maintain uniformity of thermal contact between the tip and the sample. The probe thermal resistance in vacuum when the tip is out of contact $R_{\text{vac}}$ was taken as a reference value. When the probe was brought into contact with the sample, a solid–solid heat conduction channel with thermal resistance $R_{\text{c}}$ (which is linked to the heat transport in a probed material) is opened and as a result a sudden change of the probe temperature is observed. This change is only about $2–3\%$ of the temperature difference between the heater and the sample, and due to high SThM tip apex thermal resistance the temperature of the probed material in immediate contact with the probe is much less than that of the heater.

The measured total thermal resistance of the probe $R_{\text{p}}$ in contact with the surface $R_{\text{po}}$ is a parallel combination of $R_{\text{vac}}$ and $R_{\text{c}}$ and can be obtained by solving the parallel thermal circuit, namely

$$\frac{1}{R_{\text{p}}} = \frac{1}{R_{\text{po}}} + \frac{1}{R_{\text{c}}}$$

Ultimately, the contact thermal resistance can be represented as the sum of the tip-graehene junction resistance $R_{\text{j}}$ and the graphene sheet thermal resistances $R_{\text{c}}$ where $R_{\text{c}} = R_{\text{j}} + R_{\text{c}}$. The junction resistance is dependent on the geometry and thermal conductance of the SThM tip apex as well as nature of the contacting surfaces that is sensitive to the contact area between...
Since the same SThM tip was used for all our measurements, the contacting surfaces had the same dimensions and physical nature (tip-graphene contact), and thermal resistance was observed to be independent of the applied normal force up to 100 nN (with forces used in our measurements were well below 10 nN), then $R_I$ could be safely treated as a constant. The range of values of $R_I$ can be determined from the thermal conductance per unit of area for a graphene-silicon oxide and graphene-metal interfaces that was reported to be in the range from $85 \times 10^6$ to $120 \times 10^6$ W/mK ($\pm 20\%$) and independent of the number of graphene layers. For the $50 \times 50$ nm$^2$ contact area that would result in thermal resistance between 2 to $4 \times 10^4$ K/W comparing well with our range of measured thermal resistances around $3 \times 10^4 \pm 3 \times 10^4$ K/W. Furthermore, as shown elsewhere, another component of $R_I$ is the SThM end-of tip resistance that as we confirm in our finite element analysis significantly exceeds $R_G$. Therefore, by approximating the graphene thermal resistance of the thick and highly thermally conductive 17-layer supported graphene $R_G(17L)$ as zero, an upper end estimate of junction resistance $R_J = R_G(17L) = 2.57 \times 10^6 \pm 3 \times 10^4$ K/W is obtained. This allowed us to directly link graphene sheet thermal resistance with changes in thermal resistances $R_{PI}, R_{PO}$ that are measured with the SThM setup

$$R_G \approx \frac{R_P R_O}{R_{PO} - R_{PI}} - R_G(17L)$$

In our experiments, a lower temperature of the probe (darker contrast in SThM maps) indicates higher heat flow to the sample (therefore, a lower thermal resistance of tip-sample contact, and correspondingly, a higher thermal conductance). By calibrating the SThM sensor, we were able to calculate an estimate for intrinsic graphene sheet thermal resistance. This in turn allowed us to reliably compare thermal resistances for SLG, supported and suspended bilayer graphene (BLG), and higher number of graphene layers. SThM maps (Figure 2a) show clear differences between the thermal resistance of graphene areas with varying number of graphene layers with a spatial resolution of approximately 50 nm. The increase in the number of supported graphene layers (from SLG through 3-layer (3L) and few layer graphene, FLG) lead to a clear decrease in thermal resistance. Absolute values of total contact thermal resistances $R_J$ for SLG, BLG, and a trench area with suspended BLG are estimated as $R_G(3L) = 3.35 \times 10^6 \pm 3 \times 10^4$ K/W, $R_G(BLG) = 3.15 \times 10^6 \pm 3 \times 10^4$ K/W, and $R_G(BLG-trench) = 2.75 \times 10^6 \pm 3 \times 10^4$ K/W, respectively, see Figure 2b.

One of our key observations was that the thermal conductance of BLG layer suspended over the trench exceeded that of BLG resting on substrate (darker SThM contrast of the suspended area in Figure 2a, SThM profiles in Figure 2b). This finding, could be considered counterintuitive as one might expect a better heat dissipation of supported graphene where there is an additional channel of heat transfer through thin graphene layer directly to the substrate, however it suggests that a reduction of lateral heat transport in the graphene layer due to contact with substrate has a prevailing effect. As MFP of thermal phonons in suspended graphene is much larger than the distance from the center of the trench to its border (90 nm), one can estimate (by assuming average MFP value of 600 nm$^{11,12}$ and symmetrical propagation of ballistic phonons in graphene plane) that approximately 90% of phonons from the apex of SThM tip will reach the trench border in the ballistic regime, making ballistic acoustic phonons the dominating heat escape channel in our measurement geometry. Nanoscale maps of local thermal transport in the trench area and its vicinity (Figure 2a) support original data of diffusive thermal transport in graphene received by the Raman technique on a wider area of suspended films,$^{4,6}$ while allowing direct exploration of thermal transport in graphene on a different length scale (50 nm spatial resolution in our SThM measurements vs 500–1000 nm in Raman measurements) and, correspondingly, in both ballistic and diffusive regimes of heat transfer in such systems.

In addition to the increased heat transport in thin bilayer suspended graphene, we also observed such increases in a much thicker (~6 nm or ~17 layers) graphene sheet suspended over the trench (Figure 3a) that showed similar decrease of thermal resistance $R_G$ of suspended relative to supported graphene; see
SThM maps and profiles, Figure 3b,c. Interestingly, a nearby graphene "bulge", an area of graphene that was out of contact with the surface but of opposite surface curvature, also showed lower thermal resistance, see Figure 3a,b,d. This confirms that it is the absence of contact with the substrate that increases heat transfer in a graphene sheet and rules out possible artifacts of the StHm approach, for example, due to the contact area difference that can be linked to the surface curvature.

As nanoscale thermal probe-sample dimensions $L$ approach and fall below the MFP of phonons $l$, consideration of the ballistic regime in the analysis of these data becomes essential. The theoretical analysis also predicts that thermal resistance $R$ of the contact area depends on Knudsen number $Kn = l/L$. Low Knudsen numbers $Kn \ll 1$ correspond to the diffusive transport and high $Kn \gg 1$ correspond to ballistic transport. It is shown elsewhere $^{34–36}$ that in the transition regime a good approximation for thermal resistance will be a summation of the corresponding increase in total thermal resistance of tip−substrate contact area (Area II) and its periphery (Area I), that may be specified, Figure 3b,c. Interestingly, a nearby graphene "bulge", an area of graphene that was out of contact with the surface but of opposite surface curvature, also showed lower thermal resistance, see Figure 3a,b,d. This confirms that it is the absence of contact with the substrate that increases heat transfer in a graphene sheet and rules out possible artifacts of the StHm approach, for example, due to the contact area difference that can be linked to the surface curvature.

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![Image](https://i.imgur.com/3J1Q5QG.png)

Figure 3. (a) AFM topography and (b) thermal image of a linearly extended graphene bulge in suspended MLG out of contact with the surface. Topography and StHm profiles of the trench (c) and bulge (d) areas (blue curves, topography; red curves, StHm profiles (with axis as above)) show that corrugations of similar height (2−3 nm) but opposite curvature have similar thermal resistance changes. It is to be noted that both show a clear increase of thermal conductance for suspended graphene (in bulge and trench alike), independent of the sign of surface curvatures which allows us to rule out possible artifacts of contact area difference in thermal StHm measurements.
mode toward two-dimensional heat conductivity can be expressed as
\[ \kappa = \int D(e)\nu(e)ek_0f(e) \left( \frac{d\ell}{de} \right) \frac{e}{k_bT} \, de \] (4)

where \( f(e) \) is the distribution function of phonons, \( \nu(e)_{ZA} = \pi/ (h^2c) \) and \( \nu(e)_{LATA} = 2\pi e/(h^2p_{LATA}) \) are the 2D densities of states of phonons, namely, ZA, LA, and TA phonons. Substituting values for \( D \) and integrating, obtained for BLG, \( \kappa_{ZA} \sim 4.5\pi k_b(k_B T/h)\lambda_{TA}^{ZA} \) per layer and \( \kappa_{LATA} \sim 7\pi k_b(k_B T/h)\lambda_{TA}^{LATA} \).

For two circuits consisting of a probe-tip (with radius less than \( l \)) that touches graphene in (a) the part supported by SiO\(_2\) and (b) in the middle of suspended part with width \( w \), and the thermal resistance of the tip-graphene junction \( R_j \) the total heat resistance of the circuit has the form
\[ R_{Ga} = R_j + \kappa^{-1} \ln \left( \frac{L_j}{l} \right) \quad \text{and} \quad R_{Gb} = R_j + \kappa^{-1} \ln \left( \frac{L_j}{w} \right), \]
for \( L_j > w > l \) (5)

where \( L_j \) is the length at which heat gets transferred from graphene into the underlying substrate. By comparing the difference \( R_{Ga} - R_{Gb} = \kappa^{-1} \ln(w/l) \) to the measured values we find \( l \sim 100 \) nm. This value compares well with the typical width of temperature transitions in the supported graphene that we observed in the vicinity of the trench edge (Figure 2b) and provides an estimate for characteristic length scale for heat transfer phenomena in graphene nanostructures.

Finally, one can see that nanoscale thermal mapping of border regions between supported graphene layers of different thicknesses (Figure 5a, b) show that the thermal transition observed higher thermal conductance due to ballistic phonons propagating in the 180 nm wide suspended graphene sheet, compared to the same sheet resting on the substrate. We found that the thermal conductance of a 3-layer supported graphene, per single graphene layer, was at approximately 68% of the SLG thermal conductance. Direct imaging of spatial distribution of heat transport in graphene nanostructures indicated that the MFP of thermal phonons of supported graphene is below 100 nm. We believe that this advancement opens new ground for nanoscale exploration of heat transport and heat management in graphene-based and other nanoelectronic devices.

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**Notes**
The authors declare no competing financial interest.

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**Figure 5.** (a) 1D profile of the thermal resistance across the boundary between supported SLG and BLG layers. The width of transition area for thermal resistance is ~50 nm, which is well below the average MFP of thermal phonons in suspended graphene. (b) 1D profile of the thermal resistance across boundaries between SLG, five layers (5 L), and 17 layers (MLG) of supported graphene.